

## Recent developments of the linear plasma device SWORD

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In the Comprehensive Research Facility for Fusion Technology (CRAFT) program, a divertor material/component testing project has been launched at the Institute of Plasma Physics, Chinese Academy of Sciences (ASIPP) to address the key R&D issues of plasma-facing materials/components for Chinese DEMO reactor in appropriate physical regimes, size and time scales of plasma-material interactions.

After 7-year's R&D and construction, a linear plasma facility named SWORD (Superconducting plasma Wall interactiOn lineAR Device) has been put into service successfully. This machine employs a 3 T superconducting-magnet to confine plasmas and an arc plasma torch to produce intense plasma streams with a particle flux up to several times of  $10^{24} \text{ m}^{-2}\text{s}^{-1}$ . The plasma diagnostics include emission spectrum and target probes. Additional Thomson scattering and laser interferometric measurements are under development. Recently, we have reached the milestone of 1000 s continuous discharges at  $10^{24} \text{ m}^{-2}\text{s}^{-1}$  flux. The production and measurement of such discharges are reported here.

The overarching goal of SWORD is to produce plasmas in the strongly coupled regime with a peak particle flux  $> 10^{25} \text{ m}^{-2}\text{s}^{-1}$ , a peak heat flux  $> 80 \text{ MW m}^{-2}$  and a beam size  $> 20 \text{ mm}$  simultaneously. The motivation and approach will be explained.

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